

# **Mechanical TEM Sample Preparation**

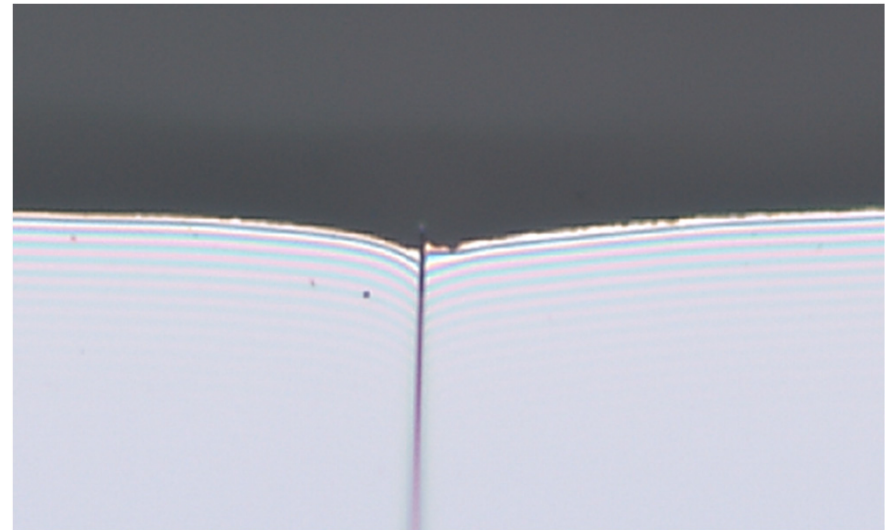
**Pablo Mendoza**

**Jessica Enos**

**Allied High Tech Products, Inc.**

# Overview

- **Basics**
  - What is a TEM sample?
  - What are the requirements?
  - What are the methods of preparing TEM samples?
- **Thin Film Preparation Process**



# What is a TEM Sample?

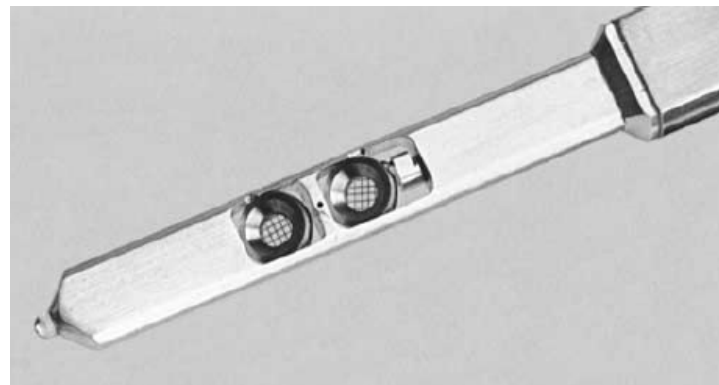
- **TEM**
  - **Transmission Electron Microscopy** is a microscopy technique in which a beam of electrons is transmitted through a specimen to form an image.
- **TEM Sample**
  - A specimen that is usually ultra thin (<100 nm) so that electrons can be transmitted through it.



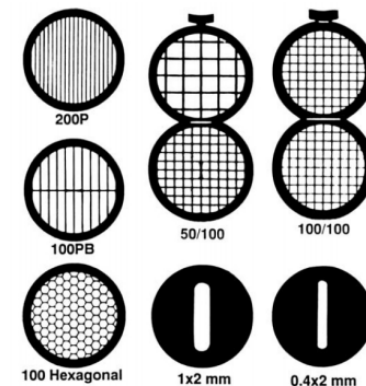
Zeiss HRTEM [3]

# TEM Sample Requirements

- Must be electron transparent
- Must have a submicron thickness
- Must have an area of  $\leq 3$  mm to fit various TEM grids and holders
- Any deformation from previous processing must be removed.



Two-specimen holder with double-tilt [3]



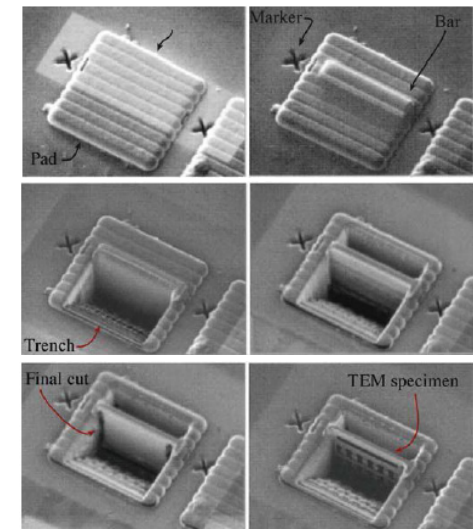
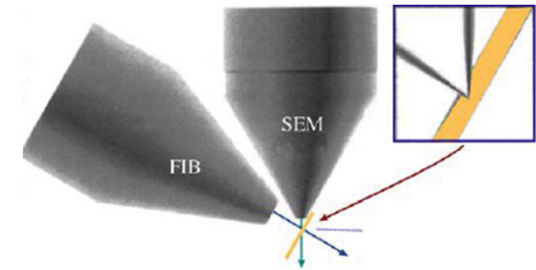
Specimen support grids of different mesh sizes and shapes [3]

# Common Methods of Preparation

- **Ion Milling/FIB**
- **Electropolishing**
- **Mechanical Preparation**
  - **Thin Film Preparation**

# Ion Milling/FIB

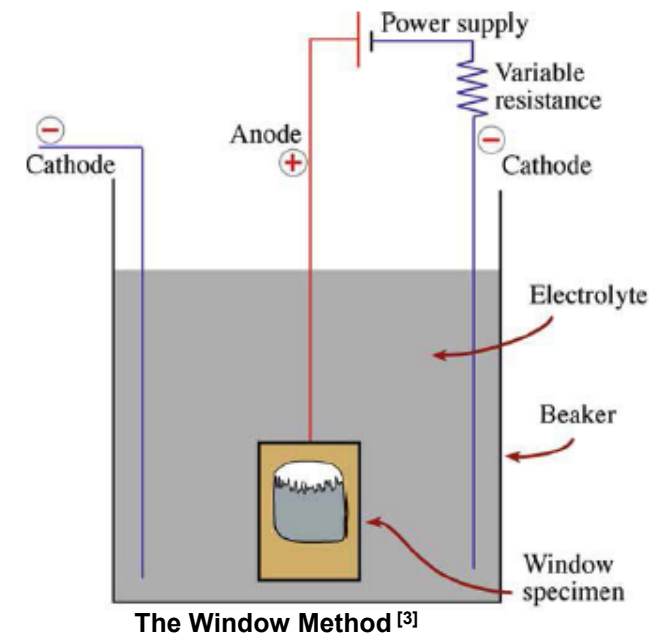
- Bombarding a TEM sample with energetic ions or neutral atoms and sputtering material from the sample until it is thin enough to study in the TEM [3]
- A versatile thinning process that can be used for a wide variety of materials
- Is expensive to purchase and run
- Implantation of source material and an amorphous layer is created



Schematic of a two-beam FIB and stages in making TEM samples using a FIB [3]

# Electropolishing

- Immersing a sample in an electrolyte and subjecting it to a direct electrical current
  - Keep the sample anodic with a cathodic connection to a nearby metal conductor [2].
  - The anodic dissolution of the sample polishes the surface.
- Relatively quick and can produce samples with no mechanical damage
- Can only be used for electrically conductive metals and alloys



# Mechanical Preparation

- Smoothing the sample surface using abrasives and mechanical tools
- Common types:
  - Manual: Uses hand tools (tripods) that allow the user to make angle adjustments
  - Semi-Automatic: Uses precision polishers with digital indicators and micrometers
  - Dimpling: Mechanical dimplers use a small-radius tool to grind and polish samples to a fixed radius of curvature in the center.





# Mechanical Preparation

- **Advantages**

- TEM Wedge Capabilities
- All damage removed using proper material removal procedures
- No foreign material implanted
- Repeatable and fast with experience
- Lower cost of required equipment
- Decreases milling time and costs

- **Disadvantages**

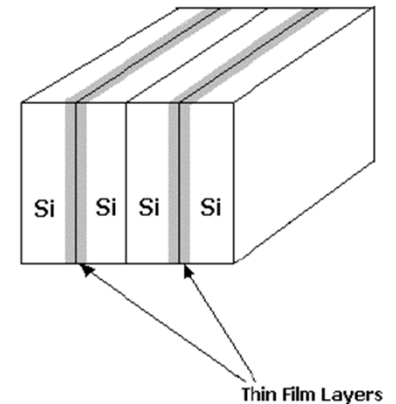
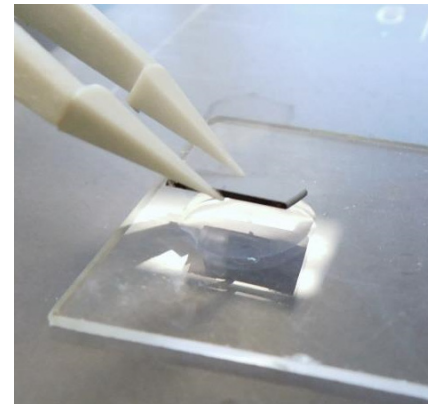
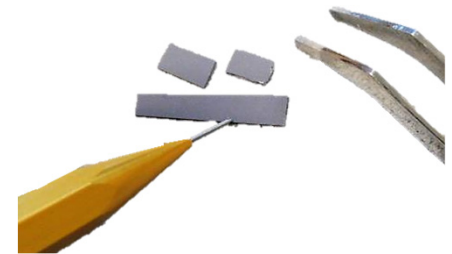
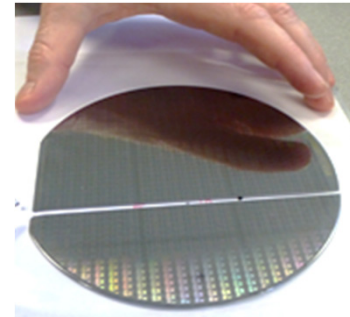
- Requires careful handling throughout the process
- Greater learning curve than other techniques
- Some samples may require additional processing using one of the other TEM preparation techniques

# Thin Film Preparation Process

- **Thin film samples are commonly prepared using mechanical methods. The process includes:**
  - **Preparing the Sample**
  - **Flipping the Sample**
  - **Fixturing**
  - **Stopping Point**
  - **Grinding the Pyrex<sup>®</sup>**
  - **Inducing a Wedge**
  - **Thinning the First Side**
  - **Color and Fringes**

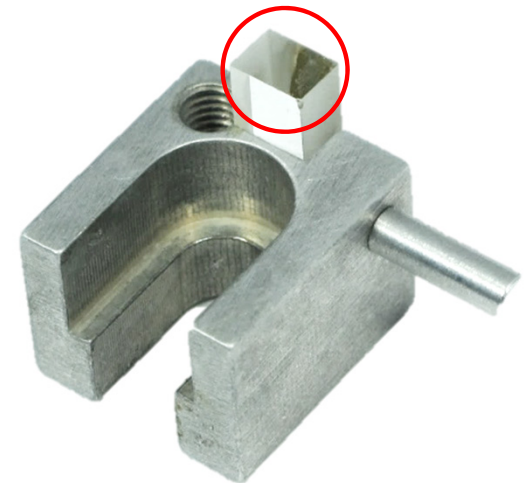
# Preparing the Sample

- **Wafers are scribed down to a manageable size.**
- **Using an appropriate adhesive, such as M-Bond 610, the thin film surfaces are “sandwiched” together.**



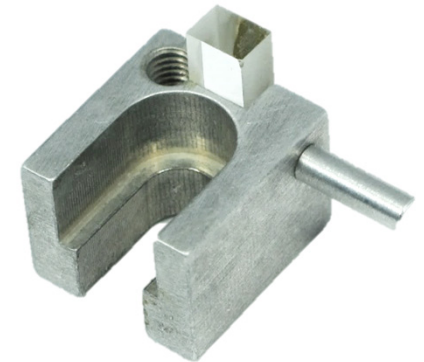
# Grinding the Pyrex<sup>®</sup>

- The surface of the Pyrex<sup>®</sup> piece on a thinning fixture requires grinding to ensure it is parallel to the platen, or the grinding plane.
- Pyrex<sup>®</sup> can be ground using diamond lapping films.
  - A 15-9  $\mu\text{m}$  finish is acceptable.
  - Do not polish the surface; having some scratches will help with adhesion.



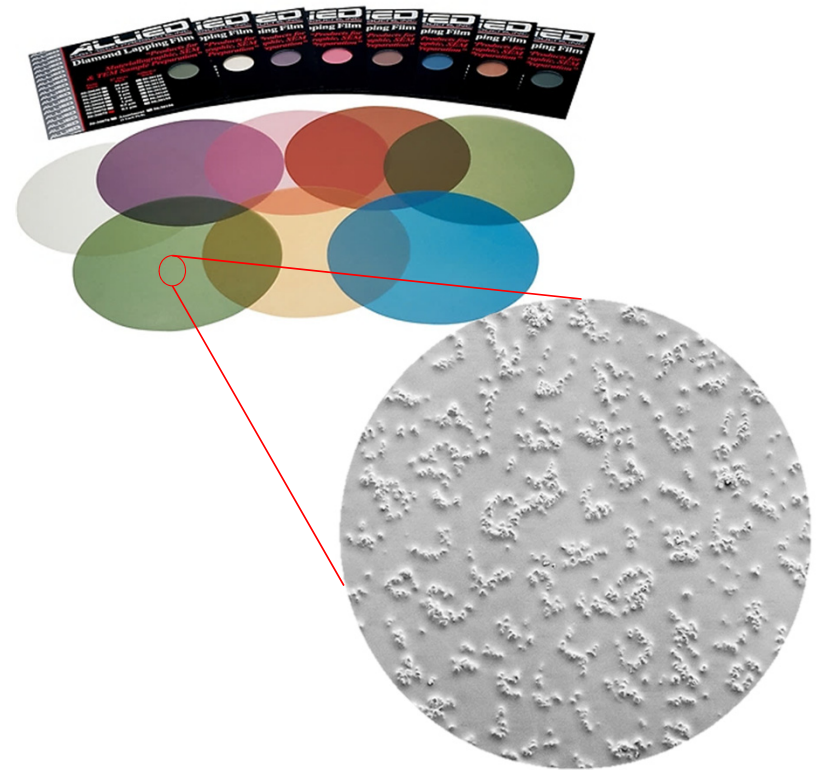
# Fixturing

- **Secure the sample on a thinning fixture with mounting wax.**
- **Place the fixture on a hot plate to melt the wax.**
- **Apply light pressure using a cotton-tipped applicator to assist in parallel registration of the sample to the fixture.**



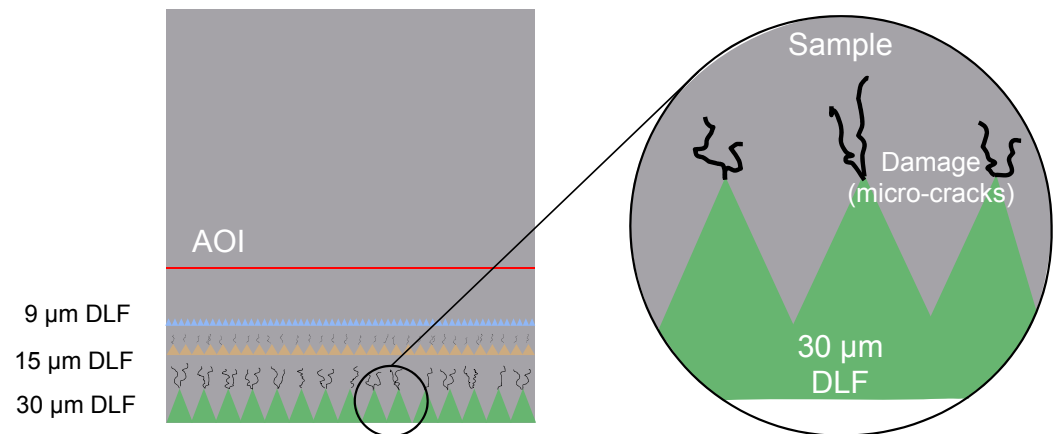
# Thinning the First Side

- **Abrasive: Diamond Lapping Films**
  - Provide excellent edge retention and maintain coplanarity
  - Typically used for unencapsulated cross-sectioning, TEM preparation, backside polishing, etc.



# Thinning the First Side

- The sample surface is damaged throughout the grinding process.
  - Scratch patterns
  - Micro-cracks that can propagate further into the sample



# 3X Rule

- **Remove 3 times the previous abrasive to completely remove any damage.**
  - **Ex: If a 30  $\mu\text{m}$  lapping film is followed by a 15  $\mu\text{m}$  lapping film, the 15  $\mu\text{m}$  film must remove at least 90  $\mu\text{m}$  (3 x 30  $\mu\text{m}$ ) to completely remove any damage.**

Current Step (DLF)	Current Distance from Target	Previous Step	Remove At Least 3x Prev. Step Size	Distance to Target After Current Step
30 $\mu\text{m}$	Varies	N/A	N/A	192 $\mu\text{m}$
15 $\mu\text{m}$	192 $\mu\text{m}$	30 $\mu\text{m}$	90 $\mu\text{m}$	102 $\mu\text{m}$
9 $\mu\text{m}$	102 $\mu\text{m}$	15 $\mu\text{m}$	45 $\mu\text{m}$	57 $\mu\text{m}$
6 $\mu\text{m}$	57 $\mu\text{m}$	9 $\mu\text{m}$	27 $\mu\text{m}$	30 $\mu\text{m}$
3 $\mu\text{m}$	30 $\mu\text{m}$	6 $\mu\text{m}$	18 $\mu\text{m}$	12 $\mu\text{m}$
1 $\mu\text{m}$	12 $\mu\text{m}$	3 $\mu\text{m}$	9 $\mu\text{m}$	3 $\mu\text{m}$
0.5 $\mu\text{m}$	3 $\mu\text{m}$	1 $\mu\text{m}$	3 $\mu\text{m}$	At Target

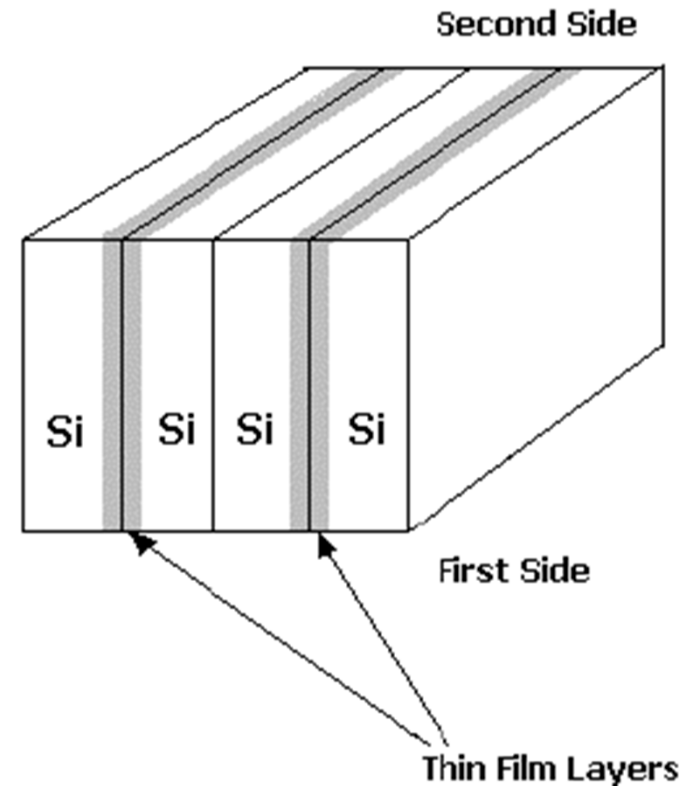


# 3X Rule

- **Certain materials, such as ductile steels, may only require a “2X Rule.”**
- **Fragile, brittle materials, such as ceramics, may require a “4X Rule” since cracks can propagate further into the sample.**
- **Main Concept: No matter what steps follow, all damage introduced by the previous abrasive must be removed to obtain an accurate representation of the microstructure.**

# Flipping the Sample

- Reheat the fixture on a hot plate.
- Carefully remove and clean the sample, and then place it back on the fixture with the polished side face down.
- Thin the sample according to the 3X rule.



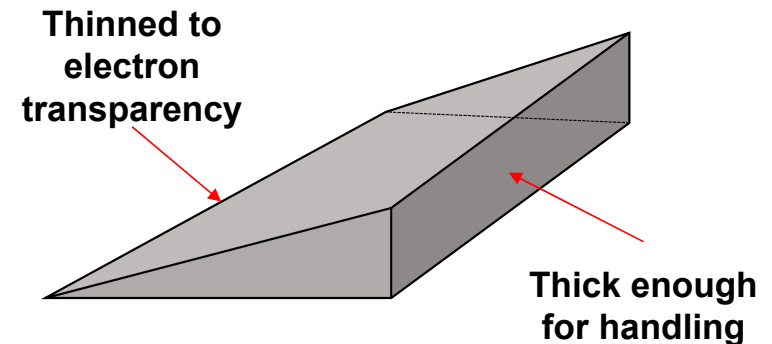
# Goal: Pre-FIB or TEM Wedge?

## Pre-FIB Thinning

- Remove the sample to prepare for FIB thinning by placing the paddle into a piece of filter paper, and then into a container of acetone to remove the wax.

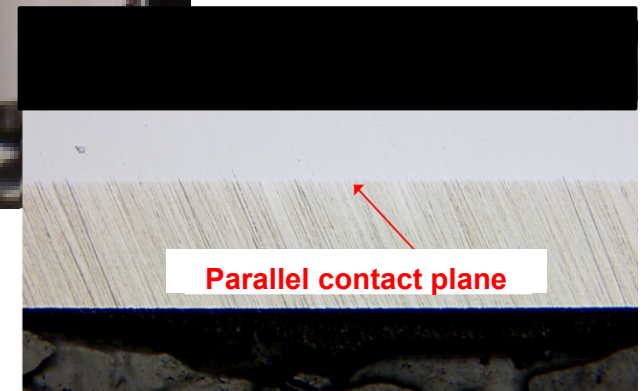
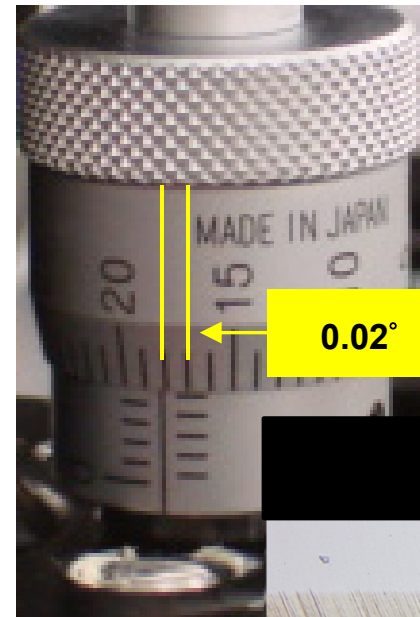
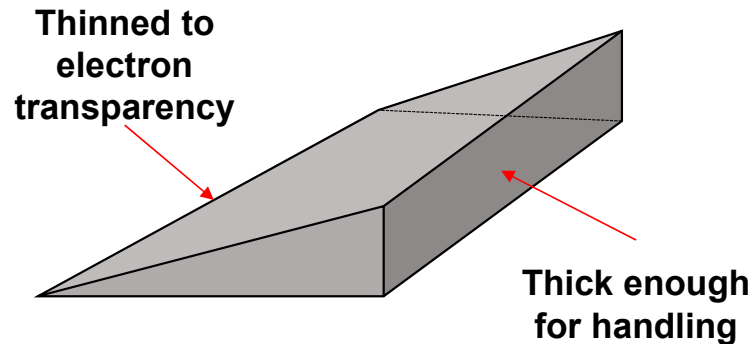
## TEM Wedge

- Induce an angle to create a wedge sample.
- The degree of the angle depends on the material being prepared.



# Inducing a Wedge

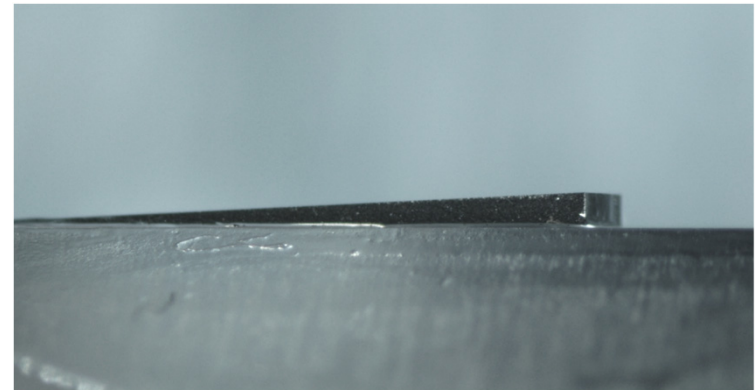
- Micrometers on precision polishers are used to induce an angle on the sample and create a wedge.



# When is the Sample Complete?

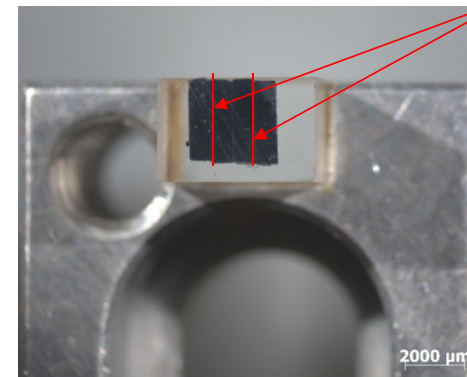
- **Bulk**

- Homogeneous material
- Can stop anywhere; only a useable area is needed



- **Thin Film**

- Film on material deposited on surface
- Prepared properly, can stop anywhere



Areas of Interest

# Color and Fringes

- **Certain TEM samples can display a series of colors in regions  $<10\ \mu\text{m}$  thick with a transmitted light microscope.**
- **Fringes can also occur in regions  $<2\ \mu\text{m}$  thick.**
- **Colors that correspond with different thicknesses vary based on materials; however, some are well documented, such as silicon.**

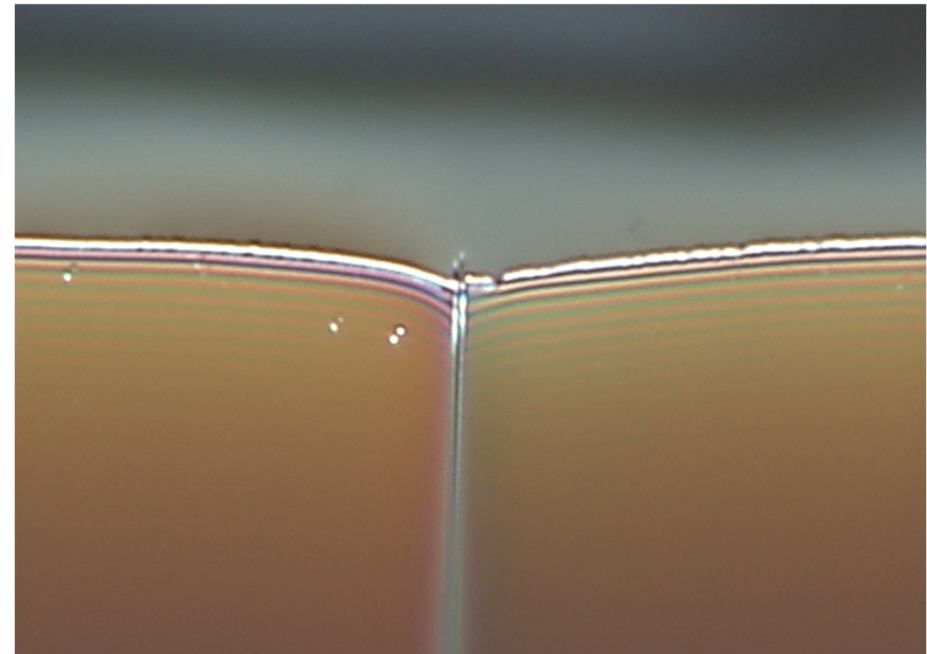


# Color and Fringes

- **Color and fringe information can be used to assist in the preparation of TEM samples, as they are a guide to overall progress during a TEM wedge procedure.**

Si thickness [ $\mu\text{m}$ ]	5	4	3	2	1
Color	Red	Reddish-orange	Orange-red	Orange	Light orange

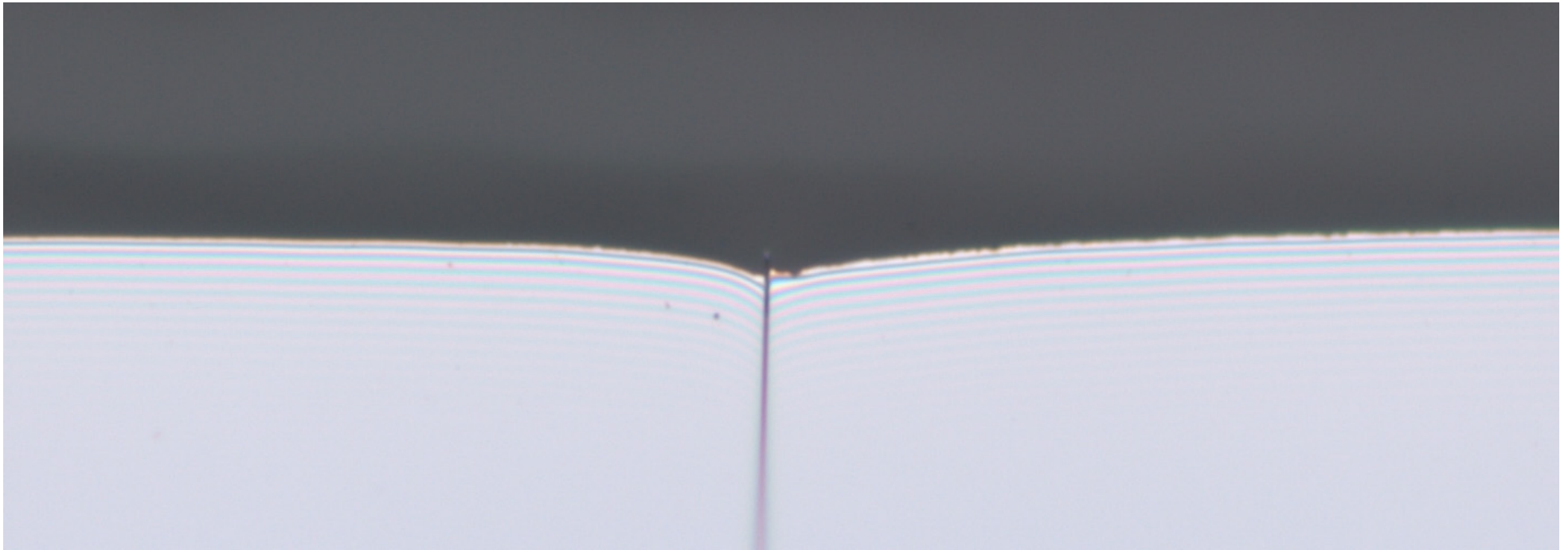
Correspondence between Si wafer thickness and color of transmitted light <sup>[4]</sup>





100 μm





# References

- 1. Allied High Tech Products, Inc., <http://www.alliedhightech.com/>. Accessed 16 September 2019.
- 2. Delstar Metal Finishing, Inc., *Electropolishing A User's Guide to Applications, Quality Standards and Specifications*, <https://www.delstar.com/assets/pdf/epusersguide.pdf>. Accessed 23 May 2018.
- 3. Williams, David B, and C B. Carter. *Transmission Electron Microscopy: A Textbook for Materials Science*. New York: Plenum Press, 1996. Print.
- 4. Yougui Liao. Practical Electron Microscopy and Database. URL: <http://www.globalsino.com/EM/page2805.html>. GlobalSino 2007.

# Questions



**Pablo Mendoza**

**Laboratory Supervisor,  
Technical Services**

**Allied High Tech Products, Inc.  
pmendoza@alliedhightech.com**

**Jessica Enos**

**Sr Materials Engineer,  
Technical Services**

**Allied High Tech Products, Inc.  
jmenos@alliedhightech.com**

**Technical Services**

**Allied High Tech Products, Inc.  
(800) 675-1118 (North America)  
(310) 635-2466 (Worldwide)  
lab@alliedhightech.com**